

Brief CV

Name	Huixiang Huang	Gender	male	Photo
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University/Department	Jimei University, Information Engineering College			
Personal Web Sites	http://faculty.jmu.edu.cn/huanghuixiang/zh_CN/index.htm			
Research Area	Semiconductor process and devices			
<p>Brief introduction of your research experience:</p> <p>Dr. Huang received the Ph.D. degree in microelectronics in 2014 from Shanghai Institute of Microsystem and Information technology, CAS and joined Information Engineering College, Jimei University, where he is currently in the Department of Microelectronics and is engaged in the education, research, and development of semiconductor process and devices for radiation tolerant applications. His current research interests include semiconductor devices and IC design, technology and measurement methodology, SOI MOSFET device modeling, and low-power and radiation-hardened SOI/CMOS IC design and fabrications.</p>				

*******All the columns need to be filled in.**